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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/712,212 11/13/2003		Michael Smith	MICRON.271A	8464	
20995	7590	02/16/2005	EXAMINER		
KNOBBE I		NS OLSON & BE	WILSON, A	WILSON, ALLAN R	
FOURTEEN			ART UNIT	PAPER NUMBER	
IRVINE, CA	A 92614		2815		

DATE MAILED: 02/16/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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1	Application No.	Applicant(s)					
	10/712,212	SMITH ET AL.					
Office Action Summary	Examiner	Art Unit	-				
	Allan R. Wilson	2815					
The MAILING DATE of this communication Period for Reply	n appears on the cover sheet wit	h the correspondence address	•				
A SHORTENED STATUTORY PERIOD FOR R THE MAILING DATE OF THIS COMMUNICATI Extensions of time may be available under the provisions of 37 Cl after SIX (6) MONTHS from the mailing date of this communication If the period for reply specified above is less than thirty (30) days, If NO period for reply is specified above, the maximum statutory properties to reply within the set or extended period for reply will, by Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	ON. FR 1.136(a). In no event, however, may a report. a reply within the statutory minimum of thirty period will apply and will expire SIX (6) MONT statute, cause the application to become ABA	ply be timely filed (30) days will be considered timely. HS from the mailing date of this communical NDONED (35 U.S.C. § 133).	tion.				
Status							
1) Responsive to communication(s) filed on	21 January 2005						
· <u> </u>	This action is non-final.						
· <u>=</u>		ers, prosecution as to the merits	is				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the ments is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims	,						
4)⊠ Claim(s) <u>1-16</u> is/are pending in the application	ation.						
	4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) 1-9 is/are allowed. 6) Claim(s) 10-13 is/are rejected.							
							7) Claim(s) 14-16 is/are objected to.
8) Claim(s) are subject to restriction a	and/or election requirement.						
Application Papers		•					
9)☐ The specification is objected to by the Exa	miner.						
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the	ne Examiner. Note the attached	Office Action or form PTO-152.					
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for for a) All b) Some * c) None of: 1. Certified copies of the priority docur 2. Certified copies of the priority docur 3. Copies of the certified copies of the application from the International But * See the attached detailed Office action for a	ments have been received. ments have been received in Appriority documents have been aureau (PCT Rule 17.2(a)).	plication No eceived in this National Stage					
	· •						
Attachment(s)							
1) Notice of References Cited (PTO-892)	4) Interview Su						
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SI 		/Mail Date ormal Patent Application (PTO-152)					
Paper No(s)/Mail Date <u>11/13/2003</u> .	6) Other:						

DETAILED ACTION

Information Disclosure Statement

The information disclosure statement filed 11/13/2003 fails to comply with the provisions of 37 CFR 1.97, 1.98 and MPEP § 609 because the reference by Sakao et al. contains no date. The reference has been placed in the application file, but the information referred to therein has not been considered as to the merits. Applicant is advised that the date of any resubmission of any item of information contained in this information disclosure statement or the submission of any missing element(s) will be the date of submission for purposes of determining compliance with the requirements based on the time of filing the statement, including all requirements for statements under 37 CFR 1.97(e). See MPEP § 609 subsection III, C(1).

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. § 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in
- (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or
- (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 10, 11 and 13 are rejected under 35 U.S.C. § 102(e) as being anticipated by Jang, U.S. Patent No. 6,649,979.

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With regards to claim 10, Jang illustrates in figures 2A-10, particularly figure 10, (entire document) a source 230b; a drain 230b; and a gate trench 220a between the source and the drain, the gate trench having nonconductive sidewalls 221 and having a first depth, wherein the transistor is surrounded by an isolation trench 210 having a second depth that is greater than the first depth, and wherein the nonconductive sidewalls of the gate trench are formed at a point toward the middle of the gate trench and away from the isolation trench.

With regards to claim 11, Jang discloses in col. 4, lines 11-12, the first depth of 220a falls within the range of about 50 nm to about 300 nm (0.05-0.3 micron).

With regard to claim 13, the second depth falling within the range of about 300 nm to about 500 nm is generally recognized as being within the level of ordinary skill in the art, especially since the first depth 220a can be 300 nm.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 12 is rejected under 35 USC § 103 (a) as being unpatentable over Jang as applied to claim 10 above, and further in view of Lin et al. ("Lin") U.S. Patent No. 6,815,290.

With regards to claim 12, Jang is discussed above, it does not show the gate trench has a rounded bottom. Lin illustrates in figures 3a-4e a gate trench has a rounded bottom. It would

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have been obvious to one of ordinary skill in the art at the time the invention was made to have a rounded bottom as part of the standard process of forming a trench.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Allowable Subject Matter

Claims 1-9 are allowed.

Claims 14-16 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is an examiner's statement of reasons for allowance:

The closest prior art, Hsu (US Patent No. 6,624,043), discloses most of the limitations of the claims, but fails to show an isolation trench filled with a nonconductive material surrounding a transistor, wherein the gate trench has sidewalls comprising the nonconductive material, which are substantially free of the substrate material. Hsu does not have the same nonconductive material surrounding the transistor and in the isolation trenches. Other prior arts have the same

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nonconductive material, but they are not free of the substrate material. Hsu also illustrates the claim 10 structure.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure: Radens et al. (illustrates having the same nonconductive material, but not free of the substrate material and sidewalls next to the isolation trench) and Matsuo (illustrates a CMOS with sidewalls and trench isolation).

Field of Search	Date
U.S. Class and subclass:	
257/329-334	08 February 2004
Other Documentation:	
None	N/A
Electronic data base(s):	
EAST (USPAT, US-PGPUB, JPO, EPO, Derwent, IBM TDB)	08 February 2004

Any inquiry concerning this communication or earlier communications from an examiner should be directed to Primary Examiner Allan Wilson whose telephone number is (571) 272-1738. Examiner Wilson can normally be reached 7:00-4:00 Monday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on (571) 272-1664. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Allan R. Wilson Primary Examiner February 14, 2005